

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Hisao YASUHARA et al.

Group Art Unit: 1745

Application No.: 09/865,468

Examiner: G. Cantelmo

Filed: May 29, 2001

Docket No.: 109375

For: METHODS AND APPARATUSES FOR PRETREATMENT OF METAL SAMPLES

PRELIMINARY AMENDMENT AND
RESPONSE TO RESTRICTION REQUIREMENT

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

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TC 1700

Sir:

Prior to initial examination, please amend the above-identified application as follows:

IN THE CLAIMS:

Please add new claim 17 as follows:

--17. A pretreatment apparatus for element analysis of a metal sample, comprising:
means for removing contaminants on the surface of the metal sample by
sputtering; and
means for cooling at least one electrode for sputtering.

REMARKS

Claims 1-17 are pending herein. By this Amendment, new claim 17 is added.

Support for claim 17 can be found in claim 1 as originally filed. Thus claim 17 does not
introduce new matter.

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